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AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

1. (currently amended) A gas sensing element comprising:

a solid electrolytic substrate having oxygen ion conductivity;

a measured gas side electrode provided on a surface of said solid electrolytic substrate so as to be exposed to a measured gas;

a reference gas side electrode provided on another surface of said solid electrolytic substrate so as to be exposed to a reference gas; and

a porous electrode protecting layer covering said measured gas side electrode, wherein a limit current density of said electrode protecting layer is in a range from 0.04 mA/mm² to 0.15 mA/mm² on a unit area of said reference gas side electrode under the following conditions:

an oxygen concentration in said measured gas is 0.1%, a measurement temperature and an-element temperature (an element surface temperature at the measured gas side of a sensing portion-portion) are not less than 600°C, and a voltage applied between the measured gas side electrode and said reference gas side electrode is 0.5V-(i.e., an oxygen pumping in the direction from the measured gas side to the reference gas side).

- 2. (new) The gas sensing element in accordance with claim 1, wherein said solid electrolytic substrate and said electrode protecting layer are integrated into a lamination body.
- 3. (new) The gas sensing element in accordance with claim 1, wherein said solid electrolytic substrate and said electrode protecting layer are sintered together.

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- 4. (new) The gas sensing element in accordance with claim 1, wherein said solid electrolytic substrate and said electrode protecting layer are integrated into a lamination body and then sintered together.
- 5. (new) The gas sensing element in accordance with claim 1, further comprising a heater.
- 6. (new) The gas sensing element in accordance with claim 5, wherein said heater comprises an insulating substrate and a heater substrate having a heater element provided on a surface thereof.
- 7. (new) The gas sensing element in accordance with claim 5, wherein a reference gas chamber is defined between said solid electrolytic substrate and said heater.
- 8. (new) A gas sensing element in accordance with claim 7, further comprising a spacer disposed between said heater and said solid electrolytic substrate and defining a peripheral wall of said reference gas chamber.
- 9. (new) The gas sensing element in accordance with claim 1, wherein a gas permeation rate of said detecting layer is 0.03cm/sec•atm to 1.5cm/sec•atm.
- 10. (new) The gas sensing element in accordance with claim 1, wherein a thickness of said electrode protecting layer is in a range from 100 μ m to 250 μ m.
- 11. (new) The gas sensing element in accordance with claim 1, wherein the electrode protecting layer has a thickness of 160 μ m and an average pore diameter of 2,600Å and a permeation rate of 0.03cm/sec•atm.